

Title (en)

METHOD OF MANUFACTURING A POLISHING PAD

Title (de)

VERFAHREN ZUM HERSTELLEN VON EINEM POLIERKISSEN

Title (fr)

PROCEDE DE FABRICATION D'UN TAMPON DE POLISSAGE

Publication

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Application

EP 98938386 A 19980805

Priority

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- US 5490697 P 19970806

Abstract (en)

[origin: WO9907515A1] Polishing pads are provided having a polishing surface formed from a hydrophilic material. The polishing surface has a topography produced by a thermoforming process. The topography consists of large and small features that facilitate the flow of polishing fluid and facilitate smoothing and planarizing.

IPC 1-7

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IPC 8 full level

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